

Influence of technological process temperature on the structure of C-Pd nanocomposite thin films

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Abstract

The work presents results of Raman spectroscopy (RS) and transmission spectroscopy studies of C-Pd films, obtained at different temperatures of the CVD process. This temperature was changed between 500° and 750° C.

Experimental setup

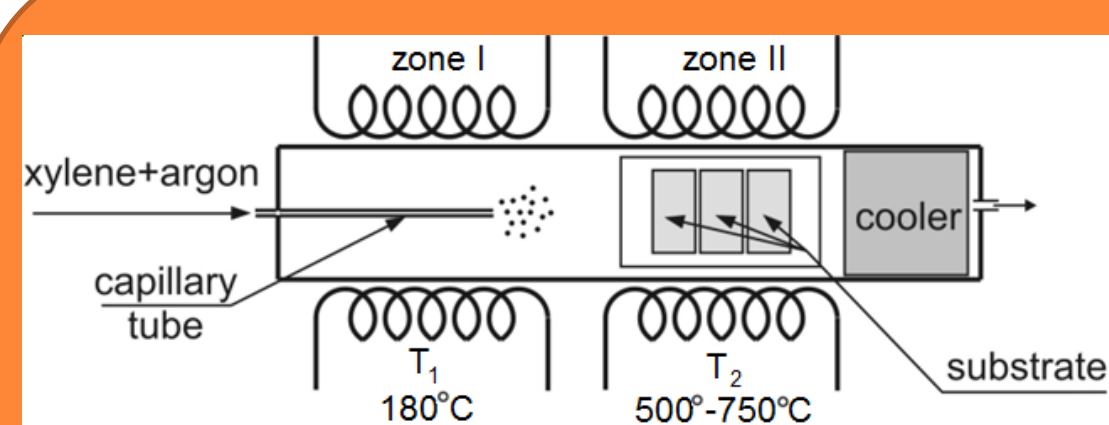


Fig. 1. Schema of experimental CVD set-up



Fig. 2. Raman spectrometer Nicolet Almega XR

The technology of obtaining C-Pd thin films by a two-phase method (PVD/CVD) was developed in the Tele & Radio Research Institute in Warsaw (Poland). In the first step of the process (PVD method) the films constituting the matrix for structures obtained in the second step (CVD method) are created. Details of technological process are described in [1–3]. Schema of CVD reactor are shown in Fig. 1. In the first zone the maximum temperature was of 180° C (T_1). In zone II temperature changes between 500 and 750° C (T_2).

Depending on the CVD process temperature the form and structure of film changes, especially taking into account carbonaceous matrix that becomes porous for temperatures higher than 600° C, while palladium nanograins embedded in such matrix remain similar (of size of few tens up too few hundred nm).

The molecular structure of films was studied by using Raman spectroscopy (Nicolet Almega XR spectrometer, excited with 532 nm line). The spectra were recorded in the range from 100 to 4000 cm^{-1} . The beam of a relatively small power, equal to 0.25mW, was focused in the area of $1\mu\text{m} \times 1\mu\text{m}$ by using the microscopic lens x50. Surface images for samples were taken using an optical microscope (Olympus B51) with x10 and x 50 lens.

Results and discussion

The film topography analysis, based on the microscopic images of samples obtained at various temperatures, confirms that the film surface changes. Grains with various diameters on the surface were observed. In the case of optical microscopic observation no influence of technological process temperature on changes of grains' sizes was observed (Fig. 3).

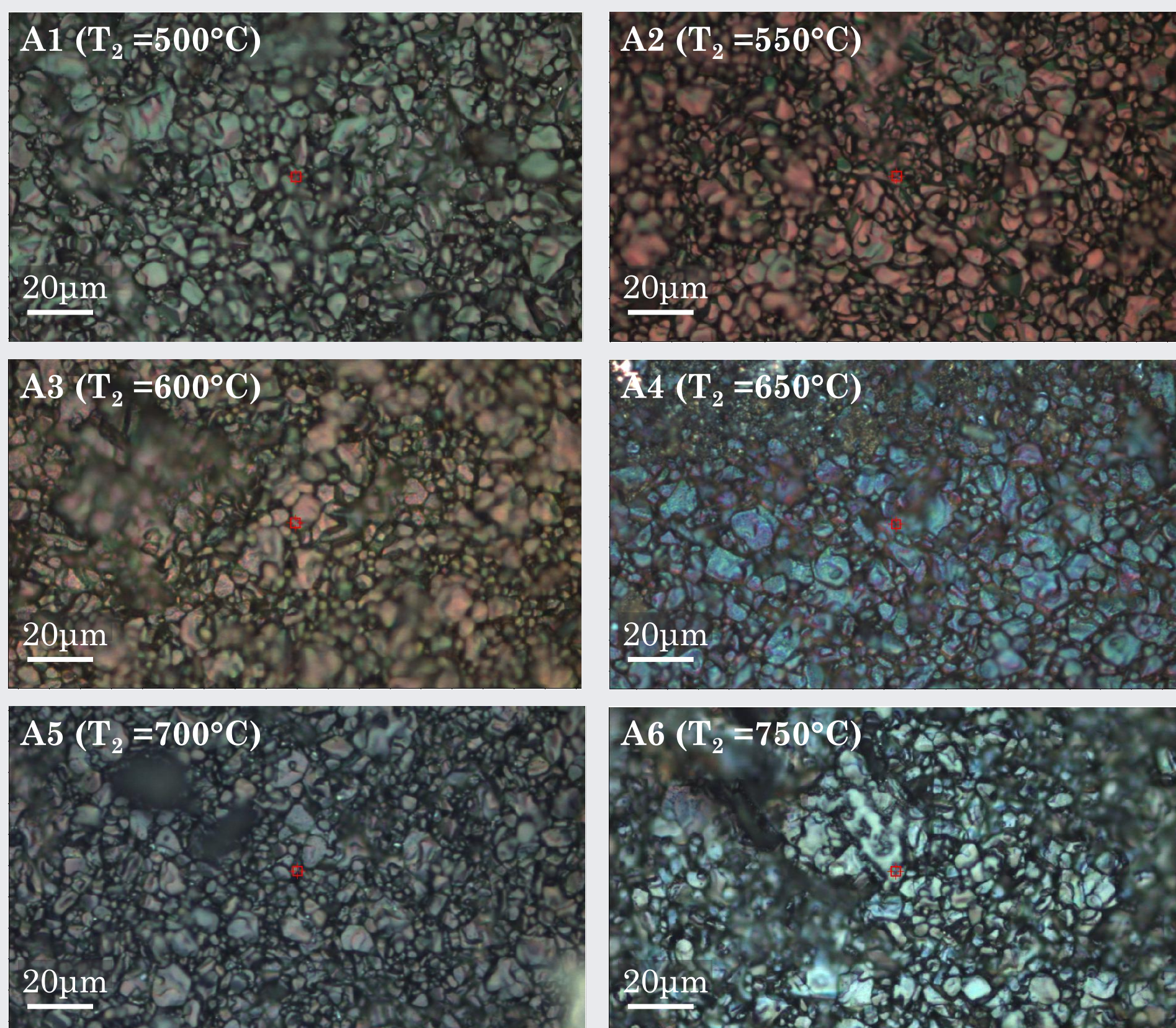


Fig. 3. Microscopic images of samples' surface obtained in CVD process (various temperatures T_2)

Raman spectra for all the samples, taking into consideration the modified process parameter, are presented in Fig. 4.

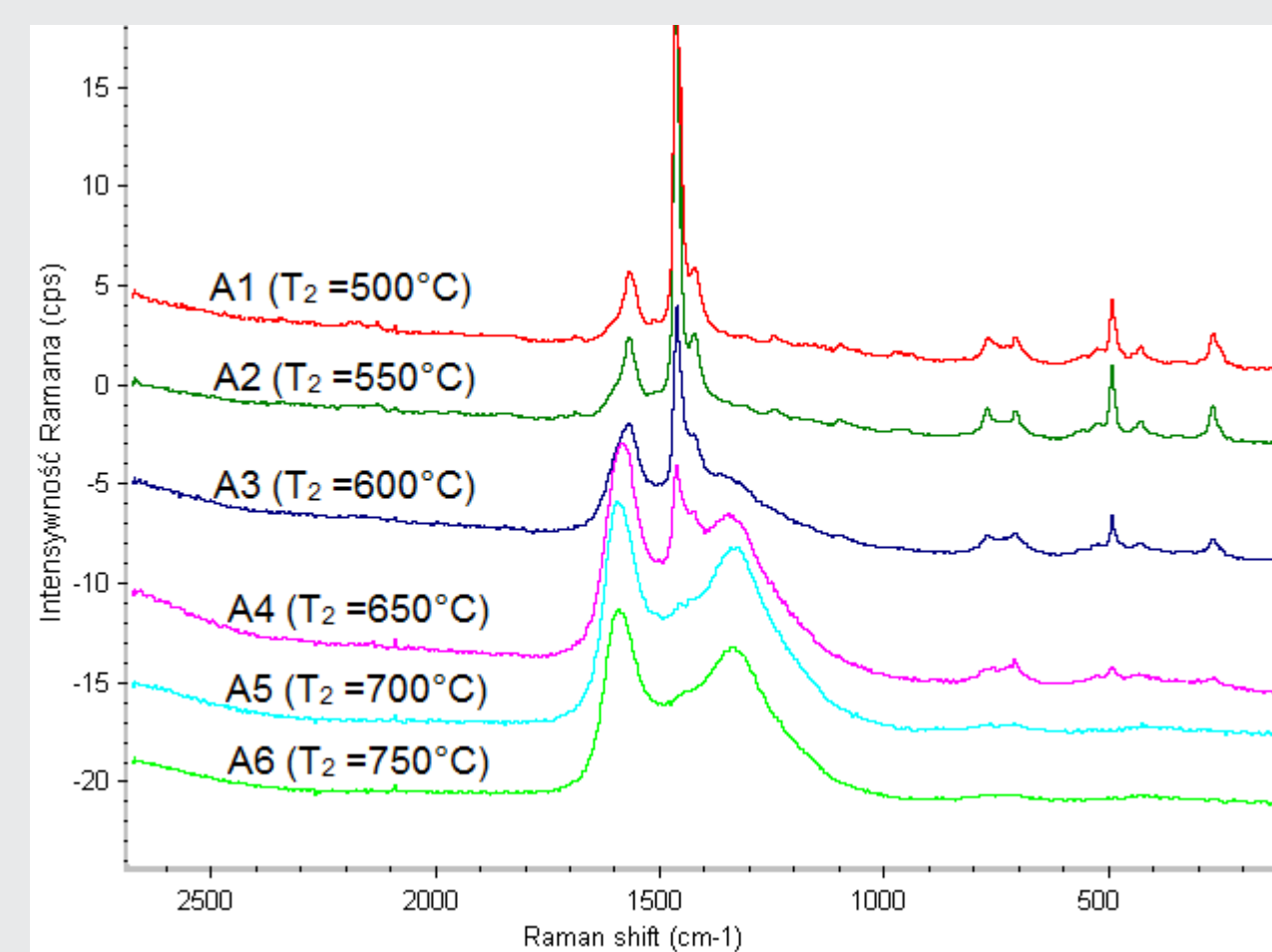


Fig. 4. Raman spectra of C-Pd films obtained in CVD process (various temperatures T_2)

In the spectra of samples obtained at lower process temperatures (500, 550 and 600°C), characteristic C_{60} fullerene spectra can be found [4]. In the spectrum of the sample obtained in 600°C the additional G and D bandwidths are observed, characteristic for amorphous graphite [5]. This can prove existence of both fullerene and amorphous carbon in the carbonaceous matrix.

In the spectra of samples obtained at higher temperatures of CVD process ($> 600^\circ\text{C}$), bandwidths with peaks at about 1350 cm^{-1} and 1585 cm^{-1} are observed. These bandwidths are identified to be D and G. The measurements carried out reveal that high process temperature influences on the type of carbon phase in the samples. The increase of temperature (T_2) facilitates degradation of C_{60} fullerene.

References

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